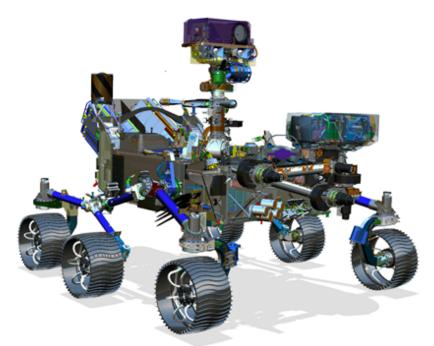


Mars 2020 RSSC Requirements and Approaches

Lauren White

Mars 2020 Deputy Contamination Control Engineer & Systems Engineer



Mars 2020 Project

The decision to implement Mars Sample Return will not be finalized until NASA's completion of the National Environmental Policy Act (NEPA) process. This document is being made available for information purposes only

Jet Propulsion Laboratory
California Institute of Technology

What's the point?

NASA

- MSPG should focus on defining the requirements (or guidelines) for sample cleanliness and clearly separate these from implementation
 - e.g. "The Mars 2020 landed system shall be capable of encapsulating samples for return such that the organic contamination levels in each sample in the returned sample set are less than Any Tier 1 compound (organic compounds deemed as essential analytes for mission success): 1 ppb"
 - Implementation: ISO 5
 cleanroom, no smokers
 allowed in the cleanroom,
 strict protocols for assembly,
 bake out of all hardware, etc.



Mars2020 Cleanliness Requirements



Mars 2020 Project

Unlike any past NASA project, Mars 2020 has requirements to control ALL of the following contamination vectors:

Forward Planetary Protection Spores



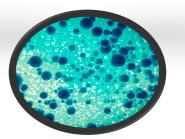
Note: not related to sample cleanliness

Return Sample Science

Viable Organisms Genetic Inventory (<1)









Tier 2: 10 ppb TOC: 10ppb

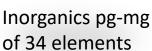
Outgassing (~1 ng/cm2/hr)

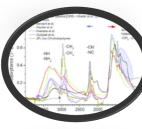












Non-volatile residue (<100 ng/cm2)

Planning Considerations Related to the Organic Contamination of Martian Samples and Implications

for the Mars 2020 Rover, Astrobiology, Volume 14, Number 12, 2014

Not Covered by M2020



Mars 2020 Project

Unlike any past NASA project, Mars 2020 has requirements to control ALL of the following contamination vectors:

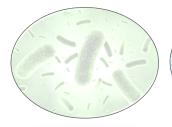
Forward Planetary Protection Spores

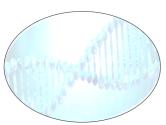


Note: not related to sample cleanliness

Return Sample Science

Viable Organisms Genetic Inventory (<1)





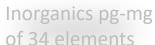


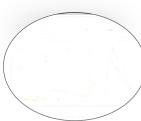


Particulate (PCL 50-300)









Non-volatile

(<100 ng/cm2)

residue

NOT covered by M2020

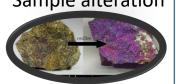
Sample extraction



Sample alteration



Backward PP



Total Organic Carbon Tier 1 Compounds: 1 ppb

Tier 2: 10 ppb TOC: 10ppb

Key and Driving Contamination Requirements



Mars 2020 Project

Organic Carbon

- each sample limited to:
 - Any Tier 1 compound (a set of 16 target biomarker compounds thought to be indicative of Martian and/or terrestrial life; or directly interfere with our ability to assess the presence of extant or extinct life on Mars*:

1 ppb

- Any Tier 2 compound (organic compounds not categorized as Tier 1): 10 ppb
- Total Organic Carbon: 10 ppb

Viable Organism

• Each sample in the returned sample set has less than 1 viable Earth-sourced organism.

Inorganic Contamination

- Each sample limited to:
 - Less than 1% of the average concentration in SNC meteorite of following elements: Zr, Nb, Ta, La, Ce, Eu, Gd, Li, B, Cs, Sc, Mn, Y, Mg, Zn, Ni, Co, Cl, Br, P, S
 - Less than 0.1% of the average concentration in SNC meteorite of following elements:K, Rb, Sr, Sm, Nd, U, Th, Re, Os, Lu, Hf, W, Pb

Future analytical techniques employed to characterize returned samples is difficult to predict.....

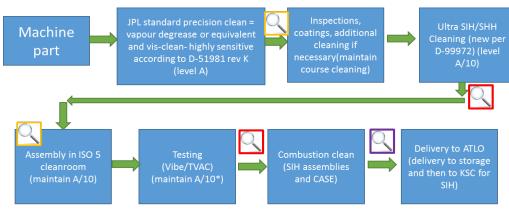


^{*} Summons, R.E., et. al. (2014) Planning considerations related to the organic contamination of martian samples and implications for the Mars 2020 rover. Astrobiology 14, doi:10.1089/ast.2014.1405.

Mode of Operation

Mars 2020 Project

- Clean all hardware, tooling, GSE down to "ultra" cleaned levels
- VHP all tools and GSE
- Keep everything in an ISO 5 environment
- Use tools and GSE to hold/touch/assemble as much as possible (metal, or foil)
- Use "aseptic" protocols to interact/assemble hardware
- Combustion clean hardware to 0.3 ng/cm2 levels and 6-log reduction of biological contamination
- Strict controls over materials (even in hardware design) /solvents/cleanroom operations
- Bakeout ALL hardware



*if leaving a cleanroom, will require carefully bagging, tenting, and certification of chambers/environments to maintain level A/10



Cleanliness sampling (no halt in assembly flow)



Cleanliness sampling (assembly flow should wait for results)



Cleanliness sampling on proxy only (assembly flow should wait for results)





Follow the part...



Mars 2020 Project

· · ·	tem (SIH/SHH) CC/I irs 2020 Document NASA JPL		Traveler
A286 Har	dware Without Dry	Lubricants	
HARDWARE: XXXXX Part Number: XXXXXXXX Serial Number: XXXXXXXX			SIH SHE
Hardware Cleanliness Requ	iirements:	Check	пг
PCL: 50 NVR:	A/10		\sqcup \sqcup
Cognizant Personnel Responsible	or Hardware:	One	
Name (Print):		Initials:	Date:
Role:			
Name (Print):		Initials:	Date:
Role:			
Name (Print):		Initials:	Date:
Role: QA Observer			
w			
The following traveler outlines procedures for completed in order and not be omitted for account in order to maintain science integring materials and procedures can be found in JP	any reason. All work and vity and verification of hard L D-99972 and JPL D-5198	verification in this doc ware cleanliness. Mc 1 REV K. By signing a 020 hardware.	ment must be an accura re detailed information t
agree to follow all procedures and standards The following materials must be used whe HPLC grade isopropyl alcohol (IPA) finitron for final rinse HPLC grade ethanol filtered to 1.2 mis rinse	Itered to 1.2 • Cleanro • Kimtech cron for final • Tools, c	om nitrile gloves (Ans	on clean process

	Precision Clean 1: Passivation per D-59181 During Part Assembly (Anse	II Nitrile Glove H	andling)
Step	Description	Complete	Initial Dat
Otep	Clean part per D-51981 methods indicated below:	Complete	IIIdai Sa
	Type 1 Method (A, B, C, D, E) or Type 2 (Detergent Cleaned)		
Pre-Clean	,, ,, ,, ,, ,, ,, ,, ,, ,, ,, ,, ,, ,,		
	Followed by: Type 3 (Alkaline Cleaning)		
	Perform passivation per D-51981. Check when complete.		
Passivation	Type IV Nitric 1 Type IV Nitric 2 Type IV Nitric 3		
Precision CI	ean 2: Type 1 Method D per D-51981 Required by D-99972 Before Ultra	Clean (Ansell Ni	trile Glove Handli
skip this sec Initial to the before ultr	itra cleaning. If passivation is completed immediately prior to ultra cleation and proceed to ultra cleaning. e right to indicate that passivation was completed immedia a cleaning.	-	
Step	Description	Complete	Initial Da
Immersion	Completely immerse parts in tank with minimum temperature of 18 °C (65 °F) with IPA.	'	
Sonicate	Soak part with sonication for a minimum of 2 minutes ₂		
Rinse	Rinse with IPA or DI water.		
Dry	Blow dry with Grade B or better nitrogen at a max temperature of 150 °F (66 °C).		
Ultra	Cleaning Procedure per D-99972 (Sterile Tool Handling, Kimtech G3 Ster	rile Gloves Post I	Jitra Clean)
Step	Description	Complete	Initial Da
Pre-wipe	Wipe hardware with Vectra Alpha 10 TX1010 sealed border wipes until no discoloration appears on wipe.		
Soak 1	Place hardware in ultrasonication unit with acetone. Fully submerge and orier so that particles fall out of hardware and into container. Place in ultrasonic bath. Soak for 3-5 minutes.	nt	
Sonicate 1	Sonicate for 2-5 minutes in acetone.		
Drain 1	Drain all solvent from all cavities of hardware into beaker.		
Rinse 1	Rinse all surfaces with fresh solvent from designated canister filled with IPA c ethanol. Alcohol shall be filtered (submicron).	or	
Soak 2	Place hardware in <u>ultrasonication</u> unit with IPA or ethanol. Fully submerge an orient part so that particles fall out of the most sample intimate hardware and into container. Place in ultrasonic bath. Soak for 3-5 minutes.		
	Sonicate for 2-5 minutes in IPA. See highlighted front page restriction.		
Sonicate 2		1	
Sonicate 2 Change Gloves	Put on Kimtech G3 sterile gloves before removing hardware before sonication bath. These should be worn through packaging the hardware.		
Change			
Change Gloves	bath. These should be worn through packaging the hardware.	iol.	

Document everything the part goes through

Verify cleanliness at the end (rinse only)

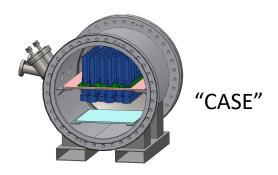
Indirectly verify cleanliness with witness plates following hardware





- Samples will need to be protected again chemical alteration → likely means an air-free environments to protect against oxidation
- Does not control for backward Planetary Protection (e.g. a potentially pathogenic Mars virus) TBD at workshop #3
- TOC and VO relies on combustion cleaning of metal parts



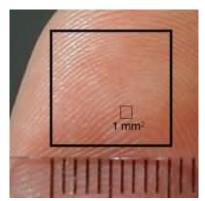


Biggest source of contaminants: Humans

Cleanrooms and associated Controlled Environments

- Biggest threat to hardware cleanliness is people
 - Skin flakes
 - Hair
 - Spittle droplets
 - Fingerprint residue
 - Clothing fibers
 - Cosmetics chemicals
 - Footwear dirt
 - Bacteria and viruses





10,000 bacteria on 1 cm⁻² skin 100 bacteria on 1 mm⁻² skin

How clean do we really have to keep hardware?



Mars 2020 Project

In order to achieve the levels described in the previous slide we MUST keep all SIH and SHH hardware clean to:

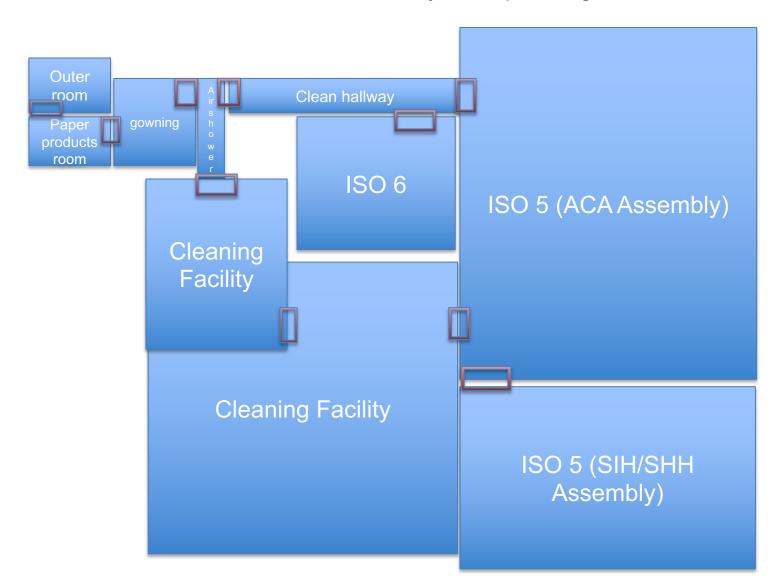
- <A/10 (100 ng/cm2) through the final firing bakeout (this is a monolayer of organic carbon on a surface)
- PCL 50-100 (depending on the hardware) (will break if exposed to anything above an ISO 5 environment)
- Sterility must be maintained at all times (non-sterile GSE or tools or the wrong gloves or solvents can change this)

Mars 2020 SCS Facilities



Mars 2020 Project

Go from clean to more clean to ultra clean as you step through the rooms



Examples of Protocols



All of the following items are **NOT ALLOWED** in these facilities

- Plastics
- Paint
- Paper (including cleanroom paper)
- Computers not "born in" cleanrooms
- Cell phone not "born in" cleanrooms
- Apply lubricants, epoxies, or perform soldering outside of designated area
- Use Kapton tape on ISO 5 flowbenches
- Introduce new equipment without CC and lead cleanroom tech approval
- desiccants



- Lot tested ESD bags, solvents, foil, gloves, EVERYTHING
- Pre-fired UHV foil
- Always fold foil over hardware then double bag and heat seal
 - Yes we tested the heat sealing!
- Only HPCL grade solvents in pre-conditioned Teflon bottles allowed
- All items in cleanroom go through "ultra" precision cleaning down to ~100 ng/cm2 and PCL 50 level (biologically clean as well)

Entrance Room VS. Gowning

Room





Pre-Entrance Room



Main Gowing Room (immediately from breezeway)



Entrance Room



Breezeway



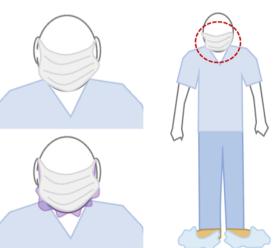
Main Gowning Room (to the left upon entry)

Mars 2020 Project

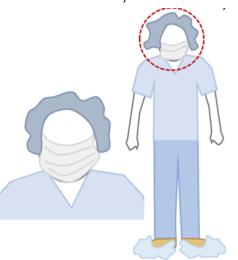
1. Clean off shoes with shoe brush cleaner. Put on foot covers and walk across the tacky mat before entering breezeway.



2. Face mask (covering nose & chin). If needed, wear beard mask BEFORE putting on the face mask.



3. Hair net (cover ears and make sure all hair tucked under).



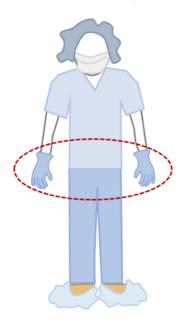
Storage of items in the entrance room will be limited. Do not plan to store your items in this area. Be sure to leave them in your office instead.



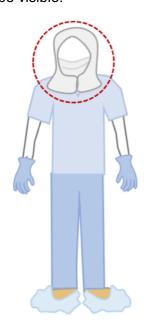
Mars 2020 Project

Gowning Room (sterile environment)

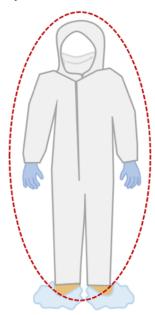
1. First glove pair, to ensure garments are handled with clean gloves.



2. Place hood over hair net. No hair should be visible.



3. Bunnysuit. Step into the suit, do not let sleeves or legs touch the floor. Ensure that hood is fully tucked into the suit.



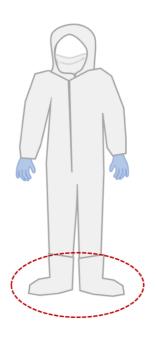
There will be no storage of items in this area. Only bring in what you absolutely must for the cleanroom (e.g. prescription glasses). All these items must be wiped down as well.

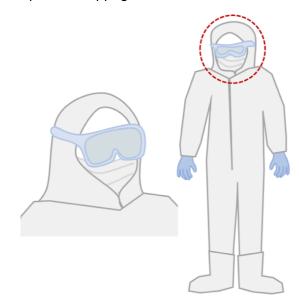


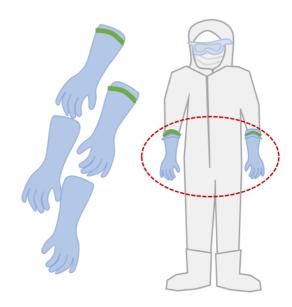
4. Put on the boot covers with the suit tucked into the boots. Fasten all the straps.

4. If 151, you may grab a pair of sterile goggles in the garment room or immediately before 151. These will be put on before entering 151 with a secure fit of the goggle straps around the head to prevent slippage.

5. All personnel will tape the first pair of gloves on. If 151: place a second glove pair on after taping. Tape should be half on the glove, half on the garment to ensure a tight seal.

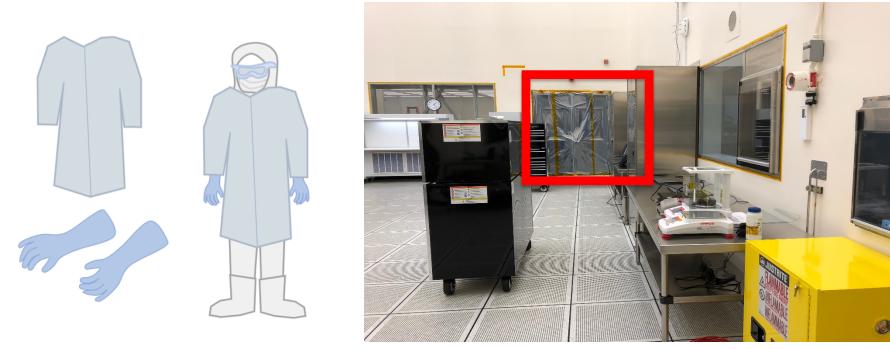








Mars 2020 Project



If entering 233-151, personnel must wear an additional smock over jump suit. The sterile smock and goggles will be put on immediately before entry to 151. The gowning area for this will be in front of the 151 entrance.

Do not hang around or do work in the sterile gowning area.

Examples of Protocols



All of the following items are **NOT ALLOWED** as personnel actions, attire, or general activities in 233-140, 141 and 151:

- Improper cleanroom attire or incorrectly worn attire (cover your nose!)
- Exceeding the max number of people allowed for a cleanroom
- Smoking within 48 hrs of assembling hardware
- Excess item storage forbidden from entrance room (before gowning room)
- Jewelry or personal phones
- Make up, skincare, and artificial nails
- Working without double gloves
- Horseplay and rapid movements
- Personal cell phones







Hygiene and Pre-Gowning



- Do not use "smelly" lotions or deodorants
- Hair product (shampoo/conditioner, hair gel/mousse/spray), after shave, and and fragrance shall not be used within 12 hrs of entering the cleanroom
- Minimize facial hair or use beard net
- No eating, drinking, smoking, gum chewing, and combing of hair in the gowning room or cleanrooms
- If you are clearly sick, or frequently coughing or sneezing. Do not come to work!

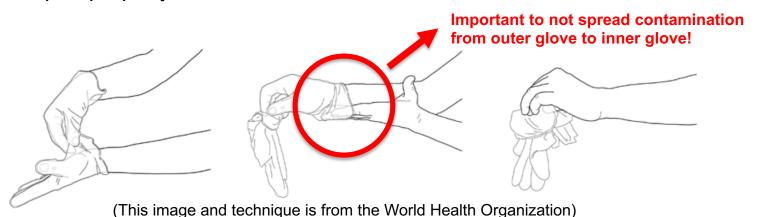


If your hair looks this stylish and smells great, you will not be allowed to work in the cleanrooms that day

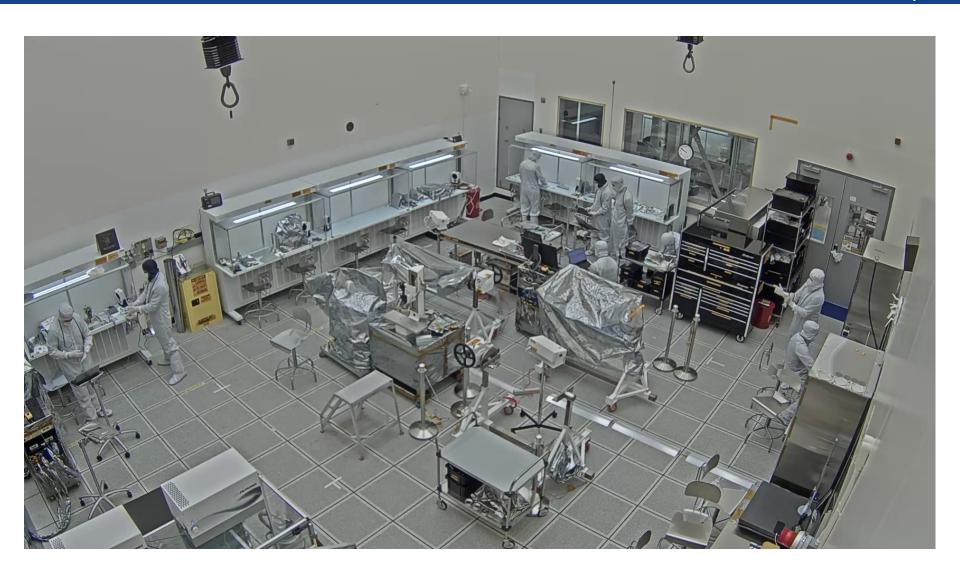
Examples of Protocols



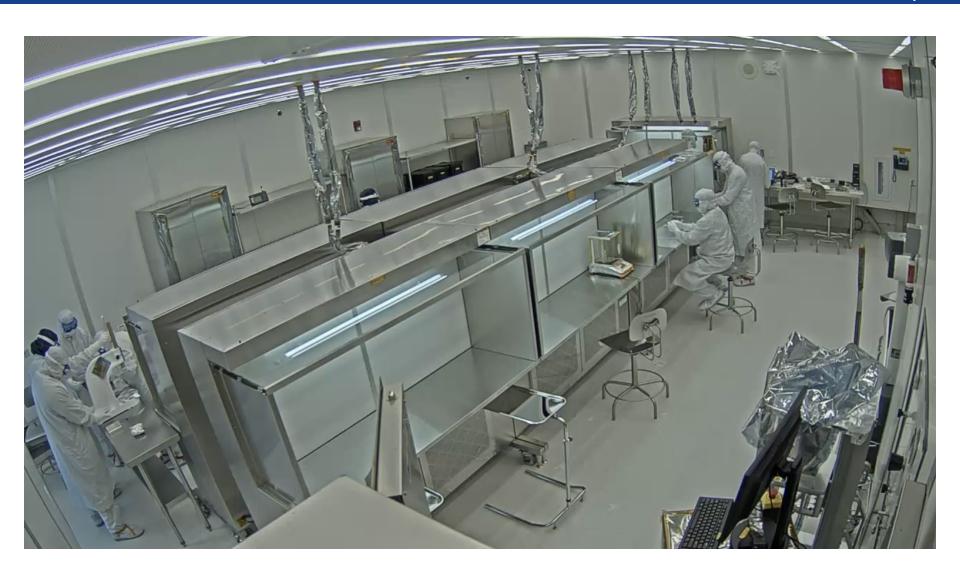
- Gloves should not be changed in or in close proximity to flight hardware
- This creates unnecessary risk of particles and organics being distributed to critical hardware!
- If there is a need to change your second glove pair:
 - 1. Walk at least three feet from the hardware
 - 2. Turn your back to the hardware
 - 3. Change your gloves by removing the top glove layer as shown below
 - 4. If you transfer contamination to your inner glove from your outer glove, you must leave the cleanroom to change the inner gloves. Be sure to de-glove the outer pair properly!



Mars 2020 Cleanrooms



Mars 2020 Cleanrooms



Mars 2020 Cleanrooms



Biological vs Organic Controls



Post autoclaved parts





Biological v Organic Controls

Mars 2020 Project





ByJulia Griffin

O
comments

Meet the mite, the tiny bugs in your mattress, your tea and on your face

Sample	Chemical Functional Group	Total Amount (µg/cm²)
Ansell nitrile cleanroom glove - no goggle	AHC	< 0.02
handling (straight from the bag)		
Ansell nitrile cleanroom glove - after	AHC (~ 96%), Silicone (~ 4%)	0.05
handling Aramark goggles		

Terminology:

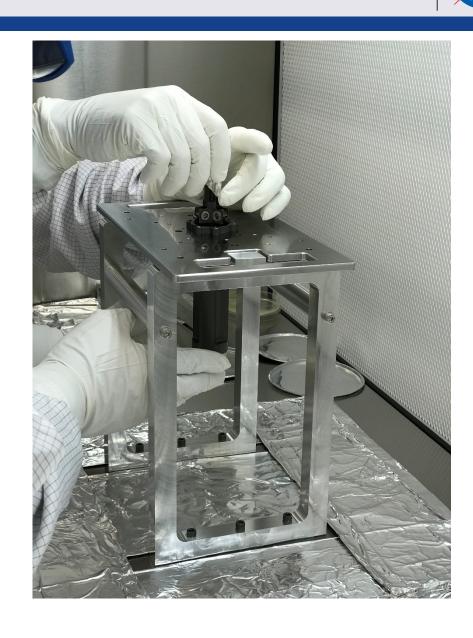
AHC: Aliphatic Hydrocarbons, base oil of lubricants, additives

Silicone: polydimethyl siloxane, commonly from RTV silicone, release agents, processing agents

Ester: common plasticizer and polymer components

μg/cm²: micrograms per square centimeter

Example of Assembly



Results



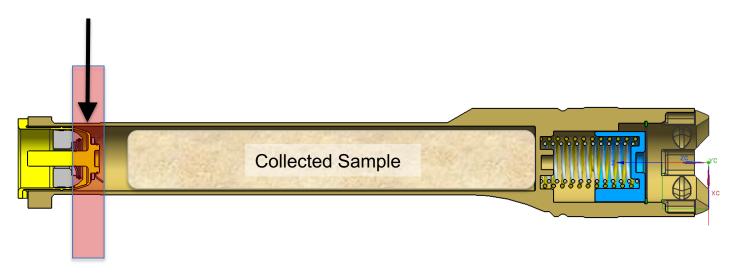
- All hardware in these facilities is meeting cleanliness requirements:
 - <0.02 ug/cm2 (requirement is <0.1 ug/cm2)</p>
 - PCL 50-100
 - Sterility requirements (< 1cfu/25cm2)
- Biggest Challenges:
 - Break down of facilities
 - The little things e.g. fiberglass insulation in a thermal chamber
 - Culture change in cleanrooms
 - Solutions that work for ALL RSSC vectors (organic, inorganic, biological, etc)



Sample Extraction

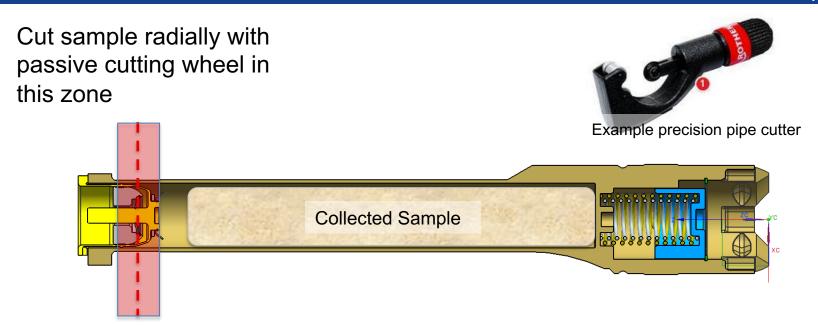
1. Sampling headspace gas





- 1. Machine the exposed TiN neck of the tube down to a thin layer (0.1-25 mm)
- 2. Clean exterior of tube of contaminants
- 3. Puncture hole in edge of sample tube between seal cup and sample using hollow-tipped awl connected to a hose





De-burr and expand edges

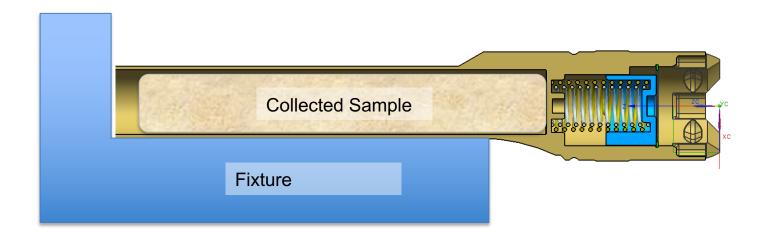


- Often, cut tubes can display burrs or a decrease in ID at the cut surface
- Smooth the inner surface to allow for gentle extraction





Rest tube in fixture



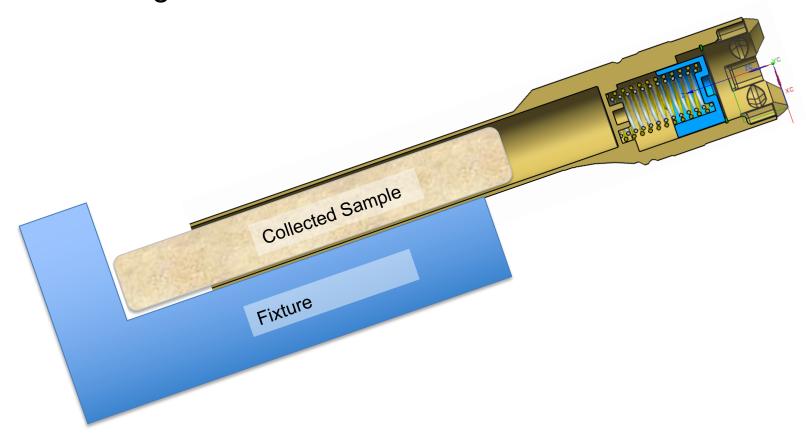


 Tilt, causing sample to slide out in collector with sample seated against edge





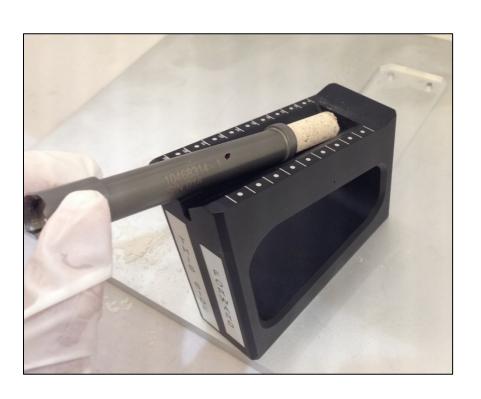
 Pull tube away from sample, agitating slightly, while keeping sample seated against base of collector





 Pull tube away from sample, agitating slightly, while keeping sample seated against base of collector







Summary



- Mars 2020 has paved the way for finding materials, protocols, cleaning specs, etc to meet all contamination vectors on hardware surfaces
- Much of this could be translated to SRF for facility cleanliness and maintenance
- Only minimal development for
 - Sample extraction
 - Sample alteration
- All contamination vectors will likely need to be met in this one space and we need to identify potential overlap/difficult areas
- We should clearly identify requirements vs implementation since there are many ways to maintain cleanliness

Ideas for Workshop #2



Focus on:

- Requirements for sample cleanliness (start with M2020 return sample requirements)
- Separate requirements from implementation
- Sample extraction
- Sample alteration prevention
- Areas where contamination vectors work against each other logistically (identify trouble areas of overlap)



backup

Organic Carbon L1 and L2



#	Topic	Text
L1-15	Organic Carbon	 The Mars 2020 landed system shall be capable of encapsulating samples for return such that the organic contamination levels in each sample in the returned sample set are less than: Any Tier 1 compound (organic compounds deemed as essential analytes for mission success): 1 ppb Any Tier 2 compound (organic compounds not categorized as Tier 1): 10 ppb Total Organic Carbon: 10 ppb Baseline, 40 ppb Threshold
L2PS - 44380	Organic Carbon	Same as L1 Baseline

Viable Organisms at L1 and L2



Mars 2020 Project

#	Торіс	Text
L1-17	Viable Organisms	The Mars 2020 landed system shall be capable of encapsulating samples for return such that each sample in the returned sample set has less than 1 viable Earth-sourced organism.
L2PS - 72265	Probability of viable Earth organism in returned sample	The Mars 2020 Project shall be capable of encapsulating samples for return such that each sample in the returned sample set has more than a 99.9% probability of being free of any viable Earth-sourced organisms.

 Note that the level 2 requirement is tighter than the Level 1 requirement by a factor of 1000

Inorganic Contamination at L2



#	Торіс	Text	Note
L2PS - 63993	Inorganic Contamination at 1% (of SNC)	The PS shall limit contamination of rock samples with Earth-sourced inorganic contaminants to no more than the contamination mass limits listed in Table IOC (all values TBC) for Zr, Nb, Ta, La, Ce, Eu, Gd, Li, B, Cs, Sc, Mn, Y, Mg, Zn, Ni, Co, Cl, Br, P, S	Holding the TBCs until completion of inorganic test program now underway See Inorganic Vectors presentation for Table IOC
L2PS - 63994	Inorganic Contamination at 0.1% (of SNC)	The PS shall limit contamination of rock samples with Earth-sourced inorganic contaminants to no more than the contamination mass limits listed in Table IOC (all values TBC) for K, Rb, Sr, Sm, Nd, U, Th, Re, Os, Lu, Hf, W.	
L2PS - 63995	Inorganic Contamination: Lead	The PS shall limit contamination of rock samples with Earth-sourced Pb contaminants to no more than the Pb contamination mass limit listed in Table IOC. (Value TBC)	